



Docket No. 0524-0140.01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
)
Nozawa et al.)
)
Serial No.: 10/667,823)
)
Filed: September 22, 2003)
)
For: Phase Mask Shift Blank, Photo Mask Blank,)
And Manufacturing Apparatus And Method)
Of Blanks)
)
Examiner: Rodney Glenn McDonald)
)
)
Art Unit: 1753)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents , P.O. Box 1450, Alexandria, VA 22313-1450 on <u>September 27 2005</u> (Date of Deposit)	
Shannon Wallace Name of applicant, assignee, or Registered Rep.	
<u>Shannon Wallace</u> Signature	<u>9/27/05</u> Date

Commissioner of Patents
P. O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT B

Dear Sir:

In response to the Office Action of May 27, 2005, a one month extension of time being submitted herewith, please amend the above-identified application as follows: